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thin solid films

Contents

Synthesis and Characterization

Interelectrode separation effects on a-SiGe:H films prepared by plasma chemical vapor deposition
J.V. Sali, A. Rashad, B.R. Marathe, M.G. Takwale, K.D. Gangurde and A.D. Shaligram 1

Titanium dioxide thin film deposited by spray pyrolysis of aqueous solution
C. Natarajan, N. Fukunaga and G. Nogami 6

The growth of hexagonal boron nitride thin films on silicon using single source precursor
C. Rohr, J.-H. Boo and W. Ho 9

Polycrystalline $RbTiOPO_4$ and $KTiOPO_4$ bilayer thin films by spray pyrolysis
N. Golego and M. Cocivera 14

Optical properties of CdS nanocrystalline films prepared by a precipitation technique
K.K. Nanda, S.N. Sarangi, S. Mohanty and S.N. Sahu 21

Laser ablation doping process for the synthesis of conductive diamond thin film
J. Gaze, N. Oyanagi, I. Yamamoto and H. Izawa 28

Phase composition of anodic oxide films on transition metals: a thermodynamic approach
A.L. Pergament and G.B. Stefanovich 33

Temperature effects on growth of boron nitride thin films by a hot filament assisted rf plasma chemical vapor deposition
X. Ma, J. Yang, D. He and G. Chen 37

Synthesis of Sn-doped a-C:H films by RF plasma-enhanced chemical vapor deposition and their characterization
Y. Inoue, T. Komoguchi, H. Nakata and O. Takai 41

UHV magnetron sputtering of silver films on rocksalt: quantitative X-ray texture analysis of substrate-temperature-dependent microstructure
F.-L. Yang, R.E. Somekh and A.L. Greer 46

Properties of indium tin oxide films prepared by rf reactive magnetron sputtering at different substrate temperature
L.-j. Meng and M.P. dos Santos 56

SEM and XPS studies of titanium dioxide thin films grown by MOCVD
P. Babelon, A.S. Dequiedt, H. Mostéfa-Sba, S. Bourgeois, P. Sibillot and M. Sacilotti 63

Crystallisation kinetics of amorphous W–Co–C sputtered films
B. Trindade and M.T. Vieira 68

Growth of diamond thin films in a cyclic growth–etch oxy-acetylene flame process
R. Kapil, B.R. Mehta, V.D. Vankar, C. Roy and A. Pradhan 74

Gallium phosphate thin solid films: structural and chemical determination of the oxygen surroundings by XANES and XPS
F. Tourtin, P. Armand, A. Ibanez, G. Tourillon and E. Philippot 85

Substrate temperature dependent properties of sprayed $CoFe_2O_4$ ferrite thin films
S.S. Bellad and C.H. Bhosale 93

Response characteristics of lead phthalocyanine gas sensor: effects of film thickness and crystal morphology
J.C. Hsieh, C.J. Liu and Y.H. Ju 98

Preparation and ferroelectric properties of $BaTiO_3$ thin films by atmospheric-pressure metalorganic chemical vapor deposition
J. Zeng, H. Wang, M. Wang, S. Shang, Z. Wang and C. Lin 104

A quasi-equilibrium model for the prediction of interlayer chemistry during diamond chemical vapor deposition
P. Mahalingam and D.S. Dandy 108

Elsevier Science S.A.

Deposition and characterization of $Zn_xCd_{1-x}S$ thin films prepared by the dip technique
S.C. Ray, M.K. Karanjai and D. DasGupta 117

Deposition and properties of germanium/carbon films deposited from tetramethylgermanium in a parallel plate RF discharge
M. Gazicki, R. Ledzion, R. Mazurczyk and S. Pawłowski 123

Pulsed laser deposition of bismuth in the presence of different ambient atmospheres
M.O. Boffoué, B. Lenoir, H. Scherrer and A. Dauscher 132

Epitaxial growth with phosphorus. 4. Application of dichloro-*t*-butylphosphine to CVD processes: the thermal chemical vapor deposition formation of copper phosphide thin films and etching of indium phosphide by dichloro-*t*-butylphosphine [1]
J.A. Glass Jr. and J.T. Spencer 138

Microstructural study of boron doped diamond films by X-ray diffraction profiles analysis
F. Brunet, P. Germi and M. Pernet 143

Poly(chloro-*p*-xylylene)/SiO_2 multilayer thin films deposited near-room temperature by thermal CVD
J.J. Senkevich and S.B. Desu 148

Determination of flatband potential for boron doped diamond electrode in 0.5 M NaCl by AC impedance spectroscopy
R. Ramesham 158

Effect of coupling of radio-frequency plasma on the growth of diamond films in a hot filament reactor
M.P. Pai, D.V. Musale, S.T. Kshirsagar, A. Mitra and S.R. Sainkar 167

Surfaces, Interfaces and Colloidal Behaviour

Surface roughening during ion-assisted film deposition
G. Carter 177

Control of domain structure of a cyanine dye Langmuir–Blodgett film
T. Watanabe, K. Asai and K. Ishigure 188

Fractal formation and tunnelling effects on the conductivity of Au/a-Ge bilayer films
C. Zhiwen, Z. Shuyuan, T. Shun, T. Mingliang, H. Jianguo and Z. Yuheng 194

Redox reaction at the two-layer interface between aluminum and electropolymerized poly(3-methylthiophene) thin solid films
K. Uehara, T. Ichikawa, T. Serikawa, S. Yoshikawa, S. Ehara and M. Tsunooka 198

Metallurgical, Protective and Hard Layers

Properties of duplex coatings prepared by plasma nitriding and PVD Ti–C:H deposition on X20Cr13 ferritic stainless steel
T. Michler, M. Grischke, K. Bewilogua and H. Dimigen 206

Properties of thin Ta–N films reactively sputtered on Cu/SiO_2/Si substrates
J.-C. Chuang and M.-C. Chen 213

Mechanics and Nanomechanics of Thin Layers

Evaluation on the tension and fatigue behavior of various PVD coated materials
Y.L. Su, S.H. Yao, C.S. Wei and C.T. Wu 218

A simple indentation stress–strain relation for contacts with spheres on bilayer structures
X.Z. Hu and B.R. Lawn 225

Third-order nonlinear optical properties of Disperse Red 1 and Au nanometer-size particle-doped alumina films prepared by the sol–gel method
S. Muto, T. Kubo, Y. Kurokawa and K. Suzuki 233

Electronics, Optics and Opto-electronics

Waveguiding properties of CdS-doped SiO_2–TiO_2 films prepared by sol–gel method
S. Juodkazis, E. Bernstein, J.C. Plenet, C. Bovier, J. Dumas, J. Mugnier and J.V. Vaitkus 238

Relationship between the structure and the optical and electrical properties of ion beam deposited CN_x films
X.-A. Zhao, C.W. Ong, Y.C. Tsang, K.F. Chan, C.L. Choy, P.W. Chan and R.W.M. Kwok 245

Electron beam stabilization and dissolution behaviors of advanced deep UV photoresist for sub 0.3 μm microelectronics fabrication
F.F. Shi and S. Yu 254

Waveguiding pulsed laser deposited Ti:sapphire layers on quartz
M. Jelínek, R.W. Eason, J. Lančok, A.A. Anderson, C. Grivas, C. Fotakis, L. Jastrabík, F. Flory and H. Rigneault 259

A comparison of the electrochemical behaviour of W–M–N (M = Ni, Ti, Al) thin film coatings on high speed steel
C.M.A. Brett and A. Cavaleiro 263

Structural, electrical and optical properties of zinc nitride thin films prepared by reactive rf magnetron sputtering
M. Futsuhara, K. Yoshioka and O. Takai 274

Luminescence of spark processed porous InP
A. Gudiño-Martínez, E. Rosendo, H. Navarro-Contreras and M.A. Vidal 282

Modulated photocurrent of evaporated copper phthalocyanine thin films
T. Tanaka, M. Matazuma and R. Hirohashi 290

Magnetics and Magneto-optics

A study on the crystallographic orientation with residual stress and electrical property of Al films deposited by sputtering
S.P. Kim, H.M. Choi and S.K. Choi 298

Determination of structure and shape of nanoclusters obtained in sulphidation of Langmuir–Blodgett layers
F.N. Dultsev and L.L. Sveshnikova 303

Langmuir–Blodgett, Biological and Related Films

Langmuir–Blodgett films of poly-*N*-vinylcarbazole prepared by radical polymerization method
J.-F. Liu, Z.-H. Lu and K.-Z. Yang 308

Thin Film Devices, Sensors and Actuators

A study of the depth dependence of photoluminescence from thin film CdS/CdTe solar cells using bevel etched samples
D.P. Halliday, J.M. Eggleston and K. Durose 314

Condensed Matter Film Behaviour

Study on annealing effects of Au thin films on Si
T.F. Young, J.F. Chang and H.Y. Ueng 319

Raman spectroscopy and X-ray diffraction study of sol–gel derived $(Pb_{1-x}La_x)Ti_{1-x/4}O_3$ thin films on Si substrates
D. Wu, A.-d. Li, C.-Z. Ge, P. Lü, C.-Y. Xu, J. Xu and N.-B. Ming 323

Properties of CdS thin films chemically deposited in the presence of a magnetic field
O. Vigil, Y. Rodrìguez, O. Zelaya-Angel, C. Vàzquez-Lòpez, A. Morales-Acevedo and J.G. Vàzquez-Luna 329

The effect of substrate and post-annealing temperature on the structural and optical properties of polycrystalline InSe thin films
M. Parlak and Ç. Erçelebi 334

Aging studies on discontinuous silver films in ultrahigh vacuum
M. Pattabi, N. Suresh, S.M. Chaudhari, A. Banerjee, D.M. Phase, A. Gupta and K. Mohan Rao 340

Author Index of Volume 322 344

Subject Index of Volume 322 346

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